



Attorney's Docket No.: 042390P7195

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:

Steven N. Towle et al.

U.S. Serial No: 09/639,625

Filed: August 15, 2000

For: Plasma Induced Depletion of
Fluorine From Surfaces of
Fluorinated Low-K Dielectric
Materials

Examiner: Douglas W. Owens

Art Unit: 2811

Commissioner for Patents
Washington, D.C. 20231

#10/B
Patent
2/20/03
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PRELIMINARY AMENDMENT AND RESPONSE

Dear Sir:

In response to the Final Office Action mailed November 18, 2002, Applicant respectfully submits a Request for Continued Examination, per 37 CFR 1.114, and further requests the Examiner to enter the following preliminary amendments and consider the following remarks.

FIRST CLASS CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage in an envelope addressed to the Assistant Commissioner of Patents, Washington, D.C. 21231

On February 3, 2003
Date of Deposit

Teresa Edwards

Name of Person Mailing Correspondence

Teresa Edwards
Signature

2/3/03
Date